

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of :
Ju-Cheol SHIN et al. : Attn: Applications Branch
Serial No. (New) : Attorney Docket No. SEC.828D
Filed: June 24, 2003 :
For: CHEMICAL VAPOR DEPOSITION METHOD FOR DEPOSITING
SILICIDE AND APPARATUS FOR PERFORMING THE SAME

Honorable Commissioner For Patents
Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT

Sir:

Preliminary to the examination of the above-identified application, the
following amendments and remarks are submitted:

In the Specification

*Kindly add the following new section between lines 2 and 3 at page 1 of the
specification:*

CROSS-REFERENCE TO RELATED APPLICATIONS

This is a divisional of Application Serial No. 09/884,993, filed June 21, 2001,
which is incorporated herein by reference in its entirety.